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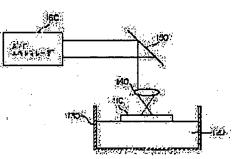
## (54) METHOD AND APPARATUS FOR MODIFICATION OF SURFACE OF FLUORORESIN

(57) Abstract:

PURPOSE: To enable an extensive surface modification of a fluororesin by bringing the fluororesin into contact with an aq. soln. of a specific compd. and irradiating the contact surface of the fluororesin with UV radiation to render the surface hydrophilic.

CONSTITUTION: An aq. soln. 120 of a water-soluble

CONSTITUTION: An aq. soln. 120 of a water-soluble compd. having a C-H bond or an N-H bond is put in a vessel 130. A fluororesin 110 is floated on the aq. soln. 120. The contact surface of the fluororesin 110 with the aq. soln. 120 is irradiated with UV radiation from a radiation source 160 via a total reflection mirror 150 and a lens 140 to render the contact surface of the fluororesin 110 hydrophilic.



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